N-DOPED NIOBIUM ACCELERATING CAVITIES: ANALYZING MODEL APPLICABILITY

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Abstract

The goal of this research was to analyse data from multiple cavities in order to test the viability of a model for surface resistance proposed previously. The model intends to describe the behaviour of the quality factor with respect to the RF field strength, while exploring the physical cause of this phenomenon; the model is pretty general, but will be checked here specifically for N-doped niobium cavities. The data were obtained from two single-cell 1.3 GHz cavities manufactured and tested at Jefferson Lab in Newport News, VA, USA.

INTRODUCTION

The slope of the quality factor Q of superconducting (sc) cavities in dependence of the accelerating gradient E, Q(E), is still a subject of debate. Several models were presented, thereof most based on a homogeneous surface and field dependent parameters.

Instead, here a model is further investigated that involves a composite surface of a homogeneous superconductor with embedded tiny weak sc defects of size comparable to the coherence length, from now on simply called "defects".

IMPURITY BASED MODEL

Our model which we will apply to the data has been partially published before [1,2]. It is based on the following assumptions, derived from many experimental data:

- i. The RF losses of a sc niobium cavity are generated by a composite from at least two origins, a pure niobium host surface with embedded defects. Their number depends on the temperature and the RF magnetic field.
- ii. These defects are themselves compounds of various purity of niobium and its alloys.
- iii. The transition to the normal conducting (nc) state of the defects occurs, by the proximity effect, at rela-

tively low RF magnetic fields and relatively low critical temperatures, as compared to the critical field and critical temperature of pure niobium.

- iv. A distinction is made for defects at the surface and those in the bulk. When a defect at the surface becomes nc, the RF field shifts deeper into the bulk. When a defect in the bulk becomes nc, the RF field does not penetrate deeper.
- v. With growing magnetic field, the defects become nc; this increases the RF losses at the surface and reduces the RF losses in the bulk.
 - a. The increase of RF losses at the surface originates from entry of magnetic flux enlarging the number of nc electrons.
 - b. The decrease of RF losses in the bulk arises from the lowering of the mean free path of the nc electrons, when the cutting edge of defects having already passed to the nc state penetrates deeper into the bulk. Their number increases logarithmically with the magnetic field (exactly valid only for a defect density constant with depth).
- vi. Above a distinct temperature (~2K), the defects, when they become nc, show enlarged RF losses. The physical reason is still unclear. Possible explanations proposed are percolation [1,2] and larger thermal impedance from the transition of the liquid helium from the superfluid to the normal fluid state [3].

To analyse the new data we use the plain ansatz as suggested by [1,2] describing a temperature independent defect density without percolation.

The significance of the different terms in relation to the preceding statements (i) – (vi) is indicated in (1). The function f(B) gives the fraction of defects already undergone nc and is chosen to unity for B=B' (at the maximum Q-value), because all defects are supposed to be nc there. The variables as used in (1) are explained in Tab. 1.

$$R_{s} = \begin{pmatrix} BCS \text{ and residual} \\ Surface resistance \\ \hline A \cdot \frac{e^{-(\Delta/T)}}{T} + R_{res} \\ \hline A \cdot \frac{e^{-(\Delta/T)}}{T} + R_{res} \\ \hline f(B) = \begin{cases} \frac{\ln(B/B_{c}^{*})}{\ln(B'/B_{c}^{*})}, B \ge B_{c}^{*} \\ 0, B < B_{c}^{*} \\ 0, B < B_{c}^{*} \\ \hline 0, B < B_{c}^{*} \\ \hline d \\ Burgerstance \\ from defects in bulk \\ \hline f(B) = \begin{cases} \frac{\ln(B/B_{c}^{*})}{\ln(B'/B_{c}^{*})}, B \ge B_{c}^{*} \\ 0, B < B_{c}^{*} \\ 0, B < B_{c}^{*} \\ \hline d \\ Burgerstance \\ from defects in bulk \\ \hline f(B) = \begin{cases} \frac{\ln(B/B_{c}^{*})}{\ln(B'/B_{c}^{*})}, B \ge B_{c}^{*} \\ 0, B < B_{c}^{*} \\ 0, B < B_{c}^{*} \\ \hline d \\ Burgerstance \\ from defects on surface resistance \\ from defects on surface \\ from defects on surf$$

 $B_{C}^{*}(T,T'^{*},B_{C0}^{*}) = B_{C0}^{*} \cdot [1 - (T/T'^{*})^{2}] \cdot \Theta(T'^{*} - T)$ (2)

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Table	1:	Variables	as	Used	in	Eqs.	(1)	and	(2))
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А	Material and frequency dependent parameter
Δ	Energy gap of niobium
R _{res}	Residual resistance
В	Maximum RF surface magnetic field
B _c	Critical magnetic field of niobium
$\mathbf{B_{c0}}^{*}$	Critical magnetic field of defect at T=0K
Т	Temperature of lHe bath
Τ,*	Critical temperature of defect in the bulk
L_2/L_1	Ratio of mean free paths at field associated
	with maximum Q and at low field
R _{s1}	Contribution to surface resistance from de-
	fects on surface
к	Ginzburg-Landau parameter

The relevant parameters for the surface resistance R_s are the penetration depth λ and the conductivity $\sigma,$

$$_{s}=(1/2)\mu_{0}\omega^{2}\lambda^{3}\sigma,$$

both depending on the mean free path L and the temperature T,

R

$$\begin{split} \lambda(T,L) &= \lambda_L(T) \sqrt{\xi_0/\xi(L)} \quad , \\ \lambda_L(T) &= \sqrt{\frac{m}{n_s(T)e^2\mu_0}} \quad , \\ \sigma(T,L) &= \frac{n_n(T)e^2L}{mv_F} \quad , \end{split}$$

with

$$\xi^{-1}(L) = \xi_0^{-1} + L^{-1}$$

 λ_L is the London penetration depth, ξ the coherence length, ξ_0 the coherence length of pure niobium, v_F the



Figure 1: Dependence on L of (a) the ratio of R_s at B-field optimum and low B and of (b) the Ginzburg-Landau parameter κ .

Fermi velocity, n_s the density of sc electrons, n_n that of the nc electrons, m the effective electron mass, and ω the RF frequency.

The "BCS" surface resistance, as derived from the twofluid model, then becomes [4]

$$R_{s,BCS} = (1/2)\mu_0 \omega^2 \lambda_L^3(T) \sigma(T,L) \xi_0^{3/2} (\xi_0^{-1} + L^{-1})^{3/2} . (3)$$

Two cases can be distinguished from (3) depending if L is large or small compared to $_0/2$. As the electrical conductivity σ of the nc electrons is proportional to L, the surface resistance is either

 $R_{\rm s} \sim L (L \gg \xi_0/2)$

or

$$R_{\rm s} \sim 1/\sqrt{L} \ (L \ll \xi_0/2)$$

The minimum of R_s hence lies at $\xi_0/2$ ($\xi_0=33$ nm for niobium). As for standard sc accelerating cavities in general, and for the nitrogen doped cavities, too, L is larger



Figure 2: Q values versus peak magnetic surface field for the 4 cavities under study.

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item	unit	RDT-14B	RDT-14C	RDT-15B	RDT-15C
treatment	-	180/20N/10+	180/20N/10+55µm	180/20N/50+	180/3N/60+10
		15µm EP	EP+180/2N/60+10µm EP	15µm EP	μm EP
# data	-	115	110	105	931
χ^2	-	51	48	27	999
А	nΩK	$(95\pm3)\cdot10^{3}$	$(90\pm 4) \cdot 10^3$	$(79\pm2)\cdot10^{3}$	$(109\pm11)\cdot10^{3}$
Δ	Κ	17.6±0.1	17.0±0.1	17.30 ± 0.05	18.2±0.2
R _{res}	nΩ	2.3±0.1	2.4±0.15	2.0±0.1	4.3±0.3
${\rm B_{c0}}^*$	mТ	14±3	<2	16.3±1.5	15±10
R_{s1}	nΩ	16±3	12±2	14 ± 3	30±8
L_2/L_1	-	0.63 ± 0.02	0.59 ± 0.03	0.30 ± 0.03	0.61 ± 0.09
T'*	Κ	>5	>3	>6.5	>3
к	-	<1.8	<1.5	<1.8	<1.8
B_{c}	mТ	200±20	200±25	200±30	200±30
B'	mТ	60±10	90±20	200±30	>120
R _{BCS} (2 K, 1.3 GHz, B <b<sub>c0*)</b<sub>	nΩ	7.2±0.6	8.8±0.5	7.0±0.3	6.6±1.6
$\Delta/(k_{\rm B}T_{\rm c})$	-	1.90 ± 0.01	$1.84{\pm}0.01$	1.87 ± 0.01	1.95 ± 0.03
Mean free path L_2 (from κ)	nm	>19	>32	>20	>20
Mean free path L_2 (from L_2/L_1)	nm	20±10	20±10	5-60	4-60
Mean free path L_1 (from L_2/L_1)	nm	84±6	92±8	235±25	100±30

Table 2: Results of fit. 180/20N/10+15µm EP means: 180 minutes @ 800°C in vacuum, 20 minutes of exposure to N2 at 800°C, 10 minutes with vacuum again @ 800°C, 15 µm Electro-Polishing (EP).

than $\xi_0/2$, the choice of L_2/L_1 as a relevant parameter in (1) is justified. Figure 1(a) displays the minimum of the ratio of the surface resistances $R_s(L)/R_{s,L=100 \text{ nm}}$.

The data were obtained on 1.3 GHz mono-cell niobium cavities made available to us from Jefferson Lab, Newport News, VA, USA. The Q vs B curves are shown in Figure 2. The characteristic features of these cavities were B/E=4.31, G=R_s·Q=277 Ω . The results of the fitting are summarized in Table 2, top. The error limits are taken from twice the minimum of χ^2 . For cavity "RDT-14C" two data sets (~2K) stuck out of the remainder and were therefore left out. After this the goodness of fits χ^2 lies below the number of data points, as it should be, except for cavity "RDT-15C" with its χ^2 slightly above. This cavity had undergone a relatively short N-doping (3 minutes) compared with the other three. All fitted parameters are in a physically sensible range.

The model of (1,2) provides a handle for understanding better the physics of N-doping by virtue of the Ginzburg-Landau parameter κ and the ratio L_2/L_1 of the mean free paths at maximum Q-value and low field Q-value. The parameter κ depends on the mean free path L according to the relation [5]

$$\kappa = \frac{2\sqrt{3}}{\pi} \cdot \frac{\lambda_L \sqrt{1 + \frac{\pi\xi_0}{2L}}}{\xi_0 \left[1 + \left(\frac{T}{T_c}\right)^2\right]} \quad , \tag{4}$$

which is displayed in Figure 1(b) for niobium with $\xi_0=33$ nm, $\lambda_L=29$ nm and $T_c=9.25$ K as typical numbers. The range for L₂, as derived from (3), stretches from >19 to >32 (Table 2, bottom). This is close or above the theoretical minimum for the surface resistance at $\xi_0/2$.

By virtue of (3), the ratio L_2/L_1 allows a second estimation of the mean free path L_2 at optimum Q-value and of the mean free path L_1 at low field (Table 2, bottom).

niobium b, Newhown in ies were tting are re taken DT-14C" nd were s, except ve. This towards the theoretical minimum. The new data hence confirm the model as presented in [2]. These findings were substantiated elsewhere, too [6,7]. **ACKNOWLEDGEMENTS** The authors are very much obliged to Dr. Charles Reece from Jefferson Lab for providing us with the data analysed here. One of us (WW) also likes to thank the staff of CLASSE, Cornell University, and in particular Michael Roman, for making available Cornell's computer facilities to perform the data analysis with Mathematica®

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In conclusion, the benefits of N-doping are caused by

the logarithmic reduction with the magnetic field of the

mean free path from about 100-200 nm at low field down

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